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## **Supporting Information**

## Directly Writing 2D Organic Semiconducting Crystals for High-Performance Field-Effect Transistors

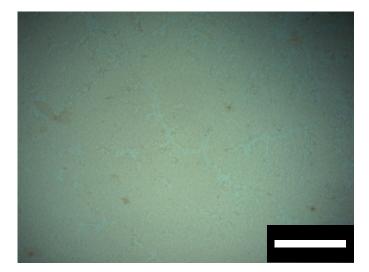
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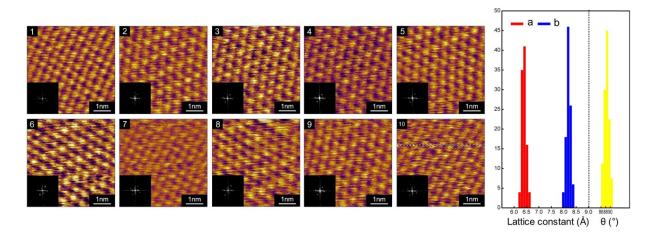
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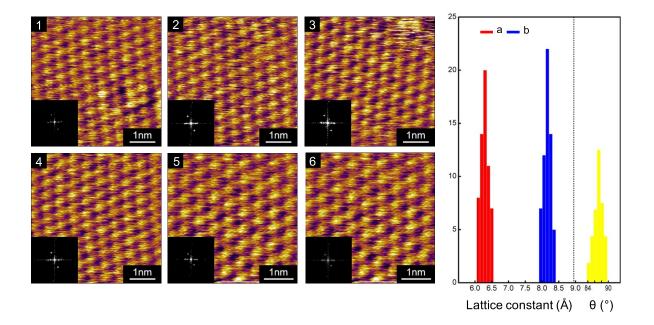
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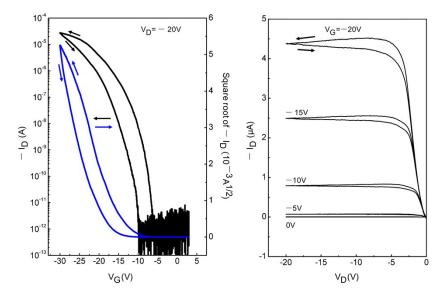
**Figure S1**. The silane of phenethyltrichlorosilane (PhTS) was used for the pretreatment on the SiO<sub>2</sub>/Si substrate surface in order to improve its hydrophilicity. The deposited organic layer mainly consists of monolayer molecules. Because of the van der Waals interaction between the C8-BTBT molecules and the substrate, the molecules in the first layer are more horizontally oriented on the substrate. It thus leads to a weak  $\pi$ - $\pi$  interaction among the semiconducting molecules, which is not favourable for the effective charge transport. Scale bar is for 50 µm.



**Figure S2**. Single-crystalline characterizations of 2L  $C_8$ -BTBT molecules. High-resolution AFM image were taken from randomly chosen areas of a 2L  $C_8$ -BTBT film. Histogram of lattice constants for 2L  $C_8$ -BTBT molecules is shown in the right figure.



**Figure S3**. Single-crystalline characterizations of 3L C<sub>8</sub>-BTBT molecules. High-resolution AFM image were taken from randomly chosen areas of a 3L C<sub>8</sub>-BTBT film. Histogram of lattice constants for 3L C<sub>8</sub>-BTBT molecules is shown in the right figure.



**Figure S4**. Transistor characteristics for the 2D C<sub>8</sub>-BTBT crystal with the highest FET device performance. (a) Transfer characteristics at drain voltage of -20 V. And a high carrier mobility of 5.9 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> was obtained. (b) Output characteristics at various gate voltage.